Youngwoo Choo

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EDUCATIONAL.	DACKODOLIND
HIDLIC ALICINAL	KACK(-KOHNI)

2012 -	Gradua	Graduate Student, Chemical Engineering		Y	Yale University				
	Thesis	Advisor: Pro	f. Chin	edum Osı	ıji				
	Project	s: Magnetic	Field	Induced	Alignment	of	Liquid	Crystalline	Block
	Copoly	mers, Electro	spray D	eposition	of Block Cop	olyn	ners		
2009 - 2011	M.S.	Chemical a	nd Biol	ogical Eng	gineering	S	eoul Na	tional Unive	rsity
	Thesis: Effect of Well-Defined Topographical Patterns on the Microdomain								
	Orienta	Orientation of Block Copolymer Thin Films							
	Thesis	Advisor: Pro	f. Kool	kheon Cha	ır				
2003 - 2009	B.S.	Chemical a	nd Biol	ogical Eng	gineering			tional Unive of Korea	rsity,

RESEARCH CAREER

Visiting Student, Center for Functional Nanomaterials		
	Brookhaven National Laboratory, Upton, NY	
	Projects: Soft Shear Laser Zone Annealing of Block Copolymers, Developing SAXS Endstation Software	
2011 - 2012	Researcher National Creative Research Initiative Center for Intelligent Hybrids Seoul National University	

MEMBERSHIP IN PROFESSIONAL ORGANIZATIONS

American Physical Society
The Polymer Society of Korea
Korean Institute of Chemical Engineers

TEACHING EXPERIENCE

2017	Chemical Engineering Laboratory and Design	Teaching Fellow
2015	Chemical Engineering Laboratory and Design	Teaching Fellow
2014	Thermodynamics for Mechanical Engineers	Teaching Fellow
2013	Ordinary and Partial Differential Equation	Teaching Fellow
2010	Chemical and Biological Process Lab	Teaching Assistant
2009	Elementary Lab for Chemical and Biological Engineering	Teaching Assistant

FELLOWSHIPS

2009 - 2010	Academic Scholarships of Seoul National University
2003 - 2009	Korean National Science & Technology Scholarship

PUBLICATIONS

^{1.} C. Kanimozhi, M. Kim, S. R. Larson, J. W. Choi, <u>Y. Choo</u>, D. P. Sweat, C. O. Osuji, P. Gopalan, "Isomeric Effect Enabled Thermally Driven Self-Assembly of Hydroxystyrene-Based Block Copolymers.", *ACS Macro Letters* **5**, 833-838 (2016)